Effects of excitonic diffusion on stimulated emission in nanocrystalline ZnO

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We present optically pumped emission data for ZnO, showing that high excitation effects and stimulated emission/lasing are observed in nanocrystalline ZnO thin films at room temperature, although such effects are not seen in bulk material of better optical quality. A simple model of exciton density profiles is developed which explains our results and those of other authors. Inhibition of exciton diffusion in nanocrystalline samples compared to bulk significantly increases exciton densities in the former, leading—via the nonlinear dependence of emission in the exciton bands on the pump intensity—to large increases in emission and to stimulated emission. © 2006 American Institute of Physics. [DOI: 10.1063/1.2174107]

ZnO has recently emerged as a strong candidate for ultraviolet photonic devices, with attractive properties, including a large exciton binding energy of 60 meV enabling efficient excitonic emission at room temperature. Many groups have studied stimulated emission and lasing properties of bulk ZnO, under electron beam and optical pumping, but evidence for stimulated emission and lasing has only been seen at rather low temperatures. Recent studies of optically pumped nanocrystalline samples reveal stimulated emission and lasing even at room temperature, in contrast to the bulk studies, even in samples of similar or inferior quality compared to bulk crystals.

We have studied optically pumped emission at room temperature from bulk single-crystal material (Eagle-Picher Corporation) and samples grown by pulsed laser deposition (PLD) on c sapphire. Details of the sample growth are given elsewhere. Some films were annealed in O2 (0.3 mbar) between 400 °C and 600 °C in the growth chamber after deposition leading to a consistent increase in grain size (30 → 80 nm) with annealing temperature. All films show evidence of electric-field damping of the free exciton (FE) and film thicknesses are in the range of 200–250 nm. The samples were studied using continuous-wave photoluminescence (PL) and high excitation pumping with a frequency-tripled Nd:YAG laser (355 nm 10 Hz 6 ns pulse width) focused on the sample to a diameter of ~1.2 mm (determined by the knife-edge method) enabling excitation intensities in the range of 500–7000 kW/cm². Full details are described in Refs. 7 and 9.

Figure 1(a) shows emission at 300 K from a PLD sample (annealed at 500 °C) as a function of increasing Nd:YAG excitation power. The data from this sample are representative of all the PLD samples. With increasing excitation, one observes the growth first of the FE band at 3.33 eV and then the P band at 3.23 eV, corresponding to the well-known exciton-exciton collision process, ~100 meV below the FE. The emission bands are significantly broadened due to the damping effects mentioned earlier. The plot of integrated emission intensity versus excitation power shown in Fig. 1(b) exhibits a distinct threshold at a pump power slightly above 2000 kW/cm², which is not explained by a superlinear power-law dependence of emission on pump level. Lasing cavity modes are seen at pump powers above this value, while no such modes are seen at lower pump powers.
Various authors have suggested that the wave-guiding properties of the air/ZnO/sapphire structure affect the stimulated emission properties leading to large gains in thin films. The critical film thicknesses identified are ~50–60 nm, substantially thinner than our films. Hence, we do not believe that this effect is appropriate to explain our data either.

A simpler explanation, not suggested before in this context, is that the FE density in nanocrystalline materials may be substantially different than that in bulk material due to the inhibition of FE diffusion in nanocrystalline samples at grain boundaries, similar to effects seen in thin films. The P- and electron-hole pair bands—in which stimulated emission and lasing are normally seen—grow in proportion to the second (or higher) powers of the FE density and are thus very sensitive to the density. In nanocrystalline samples, the FE population created by optical absorption in the ~50 nm penetration depth will be strongly confined in this volume by grain boundaries. In contrast, FE diffusion lengths in bulk material may be significantly larger. FE diffusion lengths at low temperature (<77 K) are reported in the range of 0.2–2 μm, and hence the initial exciton population will diffuse and lower its density substantially. This explanation assumes that FE are confined in the grain volume by grain boundaries but that nonradiative recombination due to deep levels at the grain boundary do not strongly quench the FE. This implies that grain boundaries repel FEs, and that FEs do not approach the boundary close enough for a high degree of nonradiative recombination. There is strong evidence throughout the literature supporting this idea, showing that high intensity PL emission (and lasing) is seen from nanocrystalline ZnO thin films even when the grain structure is pronounced. The mechanism of repulsion will probably be related to a variety of physical causes, but space-charge layers close to grain boundaries, associated with charge trapping at the boundaries, may be particularly important. Electric fields in these space-charge regions are known to be important in understanding the properties of ZnO thin films, and these samples in particular. Electric fields of a magnitude expected at grain boundaries increase the FE energy, i.e., the exciton is repelled. There is an associated quenching of the FE due to the field, mentioned above, but the dominant effect of the field is to repel the FE from grain boundaries toward low-field regions. The small FE Bohr radius (2 nm) in ZnO (Ref. 11) means that the electron and hole do not interact directly with the deep levels at the boundary when the FE center of mass is confined to the field-free region, as the space-charge regions are larger than the FE Bohr radius. This mechanism explains why the excitons are confined to the grain volume, without being strongly quenched by deep levels at the boundaries.

We use a 1D model to explore this effect for the PLD thin film and bulk samples (since the laser spot size diameter is much larger than the penetration depth of the FE population). The FE generation rate per unit area \( G \) due to the pump laser (assuming unit quantum efficiency) incident on the PLD samples is equated to the FE recombination rate per unit area \( R \) for steady state. In these samples, excitons are assumed to be confined with uniform density in the penetration depth (~50 nm, which is also typical of the sample grain sizes), represented by \( T \) in Fig. 3. The equilibrium concentration of excitons created in the polycrystalline material is given by

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\text{Exciton concentration} = \frac{G}{R} + \frac{1}{R} \int_0^T \text{Exciton density} \, dt
\]
lengths of \(~10\ \mu\text{m}\).\textsuperscript{23} Such nanowires would be expected to behave similarly to bulk material. However, these low thresholds have been reported only for nanorods grown by a metal-catalyzed (gold/self-catalyzed) process, leaving a metallic region at the nanowire tip.\textsuperscript{23} These effects can be explained by analogy with repulsive image charge effects known to efficiently exclude FE from a region close to the sample surface (“dead-layer”).\textsuperscript{16} Attractive image charge effects at a semiconductor-metal boundary may lead to FE localization close to the tip and locally high FE densities. Near-field scanning optical microscopy of single gold-tipped nanowires under high excitation\textsuperscript{23} shows light emission strongly localized at one end of the nanowire, suggesting such an exciton confinement.

In conclusion, we show evidence for high excitation effects and lasing in nanocrystalline ZnO thin films at room temperature, although such effects are not seen for bulk material of superior optical quality. Conventional explanations of such differences are not suitable to explain our results. We propose that the inhibition of FE diffusion in nanocrystalline thin films substantially increases FE densities, leading to stimulated emission and lasing. Calculations indicate differences greater than two orders of magnitude in P band and EHP emission and show why room-temperature lasing is seen only in nanocrystalline thin films, or other systems with local exciton confinement, rather than bulk material.

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